

U.S. Patent Documents

Examiner Initials	Document No.	Date	Name	Class Subclass	Filing Date If Approp.
CH	3,304,911	2/67	Hakata et al		
CH	3,494,329	2/70	Frieberger		
CH	3,540,413	11/70	Castaigue		
CH	3,566,844	3/71	Occhiodori et al		
CH	3,974,798	8/76	Meetze, Jr.		
CH	4,337,726	7/82	Czekajewski et al		
CH	4,574,734	3/86	Mandalaywala et al		
CH	4,981,106	1/91	Nagatomo		
CH	5,247,901	9/93	Landon et al		
CH	5,474,024	12/95	Hallock		
CH	5,513,596	5/96	Coiro et al		
CH	5,608,209	3/97	Matsuda		
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CH	5,915,332	6/99	Young et al		
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CH	6,234,111	5/01	Ullman et al		
CH	6,311,644	11/01	Pugh		
CH	6,542,850	4/03	Ullman et al		
CH	2002/0115725	8/02	Epstein et al		
CH	2003/0119884	6/03	Epstein et al		

Foreign Patent Documents

Document No.	Date	Country	Class Subclass	Translation Yes No
CH 2 037 140 A	7/80	United Kingdom		
CH 2 622 393 A1	5/89	France		
CH 0 363 755 A2	4/90	European		
CH 0 505 049 A1	9/92	European		

Other Documents (including Author, Title, Date, Pertinent Pages, etc.)

Examiner

Chanda L. Harris

Date Considered

1/19/05

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